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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/961,055	09/24/2001	Masaaki Hiroki	0756-2367	6718
31780	7590	02/18/2009	EXAMINER	
ERIC ROBINSON			QI, ZHI QIANG	
PMB 955				
21010 SOUTHBANK ST.			ART UNIT	PAPER NUMBER
POTOMAC FALLS, VA 20165			2871	
			MAIL DATE	DELIVERY MODE
			02/18/2009	PAPER

**Please find below and/or attached an Office communication concerning this application or proceeding.**

The time period for reply, if any, is set in the attached communication.

<b>Office Action Summary</b>	<b>Application No.</b> 09/961,055	<b>Applicant(s)</b> HIROKI ET AL.	
	<b>Examiner</b> MIKE QI	<b>Art Unit</b> 2871	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

#### Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

#### Status

- 1) ☒ Responsive to communication(s) filed on 04 December 2008.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

#### Disposition of Claims

- 4) ☒ Claim(s) 6,7,9,19,21,39,40,42,44-47 and 59-73 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_\_ is/are allowed.
- 6) ☒ Claim(s) 6,7,9,19,21,39,40,42,44-47 and 59-73 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_\_ is/are objected to.
- 8) ☐ Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

#### Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on \_\_\_\_\_ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.  
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

#### Priority under 35 U.S.C. § 119

- 12) ☒ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☒ All b) ☐ Some \* c) ☐ None of:
- ☐ Certified copies of the priority documents have been received.
  - ☒ Certified copies of the priority documents have been received in Application No. 07/837,394.
  - ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

\* See the attached detailed Office action for a list of the certified copies not received.

#### Attachment(s)

- |  |   |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)          | 4) <input type="checkbox"/> Interview Summary (PTO-413)           |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | Paper No(s)/Mail Date. _____                                      |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO/SB/08)          | 5) <input type="checkbox"/> Notice of Informal Patent Application |
| Paper No(s)/Mail Date _____  | 6) <input type="checkbox"/> Other: _____                          |

## DETAILED ACTION

### *Specification*

1. The amended title of the invention filed on December 4, 2008 is not descriptive. Because any electro-optical display device would have thin film transistors as switching device that is not an inventive technical feature. A new title is required that is clearly indicative of the invention to which the claims are directed.

### *Claim Rejections - 35 USC § 103*

2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

3. Claims 6, 7, 9, 19, 21, 39, 40, 42, 44-47, 59-61 and 64-73 are rejected under 35 U.S.C. 103(a) as being unpatentable over US 5,051,570 (Tsujikawa et al) in view of US 6,235,563 B1 (Oka et al), US 4,007,294 (Woods et al), and further in view of US 4,778,258 (Parks et al).

Regarding claims 6, 7, 9, 39, 40, 42, 59-61, 64 and 65, Tsujikawa teaches (col.10, line 36 - col.11, line 39; Fig. 9) an electro-optical display device (liquid crystal display device) comprising:

- a first substrate (128) having an insulating surface (glass substrate);
- at least one thin film transistor (103,104) formed over the first substrate (128), the thin film transistor (103,104) having a semiconductor film including channel forming region, source and drain regions, such as electrodes (117,118) with the channel

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- forming region extending therebetween (the electrodes and the channel region should be formed in a semiconductor layer), and a gate electrode (112, 113) over gate insulating film (such as 134, 135), and because the dielectric film (121) also having a function as gate insulating film, so that such insulating film (121) having a source contact hole or a drain contact hole as a first and second contact holes at the left side and right side of the channel region as shown in Fig.9B;
- an interlayer insulating film (122) formed over the thin film transistor (103,104), and such interlayer insulating film (122) having a contact hole such as one of the source contact hole or the drain contact hole, so that the interlayer insulating film (122) would have a second contact hole, and the insulating film (122) and the dielectric insulating film (121) together also functions as an interlayer insulating film so as to contact the gate electrode (112, 113);
  - an electrode (such as 118) formed over the interlayer insulating film (122) and electrically connected to the source region or drain region through contact holes (first and second or source and drain contact holes) of the interlayer insulating film (122), so that the electrode (such as 118) is in contact with the one of the source and drain regions in the first contact hole (one of the contact holes);
  - a leveling film (123) comprising organic resin formed over the electrode (such as 118), because the interlayer insulating film (123) formed of polyimide (organic resin) and functions as flatten the surface as shown in the Fig.9, and such leveling film (123) has a third contact hole as shown in Fig.9B;

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- a pixel electrode (124) formed over the leveling film (123) and electrically connected to the electrode (such as 118) through the third contact hole as shown in Fig.9;
- such third contact hole is located apart from or does not overlap the first contact hole and the second contact hole (source contact hole and drain contact hole ) as shown in Fig.9B;

(concerning claims 9. 42, 59, 60, 64 and 65)

- silicon oxide film (141) functions as a blocking layer formed over the substrate (128), and the semiconductor film (channel forming region) is surrounded by the blocking layer (141) and the gate insulating film (134, 135, 121) as shown in Fig.9B;

(concerning claims 39, 40, 42 and 60)

- the electro-optical display having an active matrix type display can be used in any electronic device such as camera in the preamble of the claims that are only given weight as intended use, and that would have been at least obvious.

Tsujikawa further teaches that the gate insulating film is formed of silicon oxide (see col.8, lines 16-18, that is the same as shown in the Fig.9 of the gate insulating film 134,135, and the dielectric film 121 also can be formed of silicon oxide as the insulating property and that is obvious in the art), but Tsujikawa does not explicitly teach that:

1) the interlayer insulating film itself is in contact with the gate electrode such as shown in Fig.6G of this application;

2) the gate insulating film covering the semiconductor film and in contact with a top surface and side surfaces of the semiconductor film;

3) the gate insulating film contains fluorine;

4) the pixel electrode is transparent.

**Oka** teaches (see Fig.4H) that an interlayer insulating film (410) formed over the thin film transistor, wherein the interlayer insulating film (410) has a contact hole (413) (the contact hole at the drain region would be a second or drain contact hole) and is in contact with the gate electrode (406) as shown in Fig.4H.

**Oka** further teaches (see Fig.4H) that the gate insulating film (405) covering the semiconductor film (the source region 407, silicon film 403, drain region 408 would be the semiconductor film) and in contact with a top surface and the side surface of such semiconductor film as shown in Fig.4H.

Oka indicates (see col.15, line 62 – col.17, line 21) the larger an increase in ON current of a TFT being achieved in such semiconductor device.

Therefore, it would have been at least obvious to those skilled in the art at the time the invention was made to modify the electro-optical display device of Tsujikawa with the teachings of arranging the interlayer insulating film having contact hole and being in contact with the gate electrode , and the gate insulating film covering the semiconductor film as taught by Oka, since the skilled in the art would be motivated for achieving the larger an increase in ON current of a TFT.

Tsujikawa and Oka teach the invention set forth above except for that the gate insulating film contains fluorine, the gate insulating film covering the semiconductor film and in contact with a top surface and side surfaces of the semiconductor film, and the pixel electrode is transparent.

**Woods** teaches (abstract) that a method of treating a layer of silicon dioxide in

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which an fluoride compound is applied to one surface of the silicon dioxide layer to prevent the deleterious effect resulting from any mobile impurity ions therein, so that would obtain more protection.

Therefore, it would have been obvious to those skilled in the art at the time the invention was made to modify the electro-optical display device of Tsujikawa and Oka with the teachings of the gate insulating film having fluorine as taught by Woods, since the skilled in the art would be motivated for preventing the deleterious effect resulting from any mobile impurity ions therein (abstract).

Concerning pixel electrode is transparent that would be a conventional.

**Parks** teaches (col.5, lines 15-20) in general, pixel electrode having transparent material (transparent pixel electrode), and that is particularly useful in LCD displays in which back lighting is employed to form or assist in forming the desired image.

Therefore, it would have been obvious to those skilled in the art at time the invention was made to modify the electro-optical display device of Tsujikawa, Oka and the film treatment of Woods, and using transparent pixel electrode as taught by Parks, since the skilled in the art would be motivated for achieving a desired image, particularly, for the transmission type liquid crystal display as indicated in paragraph [0147] of this application.

Regarding claims 19, 44, 66 and 67, Tsujikawa teaches (col.11, lines 18-23; Fig.9) that the liquid crystal (125) is disposed between the first substrate (128) and the second substrate (127), and that is conventional.

Regarding claims 21, 45, 68 and 69, Tsujikawa teaches (col.11, lines 30-33; Fig.9) that the leveling film (123) comprises polyimide, because the interlayer insulating film (123)

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functions as flatten the surface as shown in the Fig.9, such that the interlayer insulating film (123) is a leveling film.

Regarding claims 46, 70 and 71, Tsujikawa teaches (col.10, lines 43-55; Fig.9) that the channel region (between the source region and the drain region of the thin film transistor) comprises crystalline silicon.

Regarding claims 47, 72 and 73, Tsujikawa teaches (col.8, line 16-18) the gate insulating film comprises silicon oxide (the Fig.6 shows the same as the Fig.9 for the gate insulating film 134, 135, and the dielectric film 121 also can be formed of silicon oxide as the insulating property and that is obvious in the art).

4. Claims 62-63 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tsujikawa, Oka, Woods and Parks as applied to claims 6, 7, 9, 19, 21, 39, 40, 42, 44-47, 59-61, and 64-73 above, and further in view of US 5,054,887 (Kato et al).

Regarding claims 62-63, Tsujikawa, Woods, Shimbo and Parks teach the invention set forth above except for the gate electrode does not overlap the pixel electrode.

Kato teaches (see Fig.1 and 2) that the gate electrode (28) does not overlap the pixel electrode (24), and that is a common and known in the art as normal arrangement the pixel electrode does not overlap the TFT formed region, and that would have been at least obvious.

### ***Response to Arguments***

5. Applicant's arguments with respect to claims 6, 7, 9, 19, 21, 39, 40, 42, 44-47 and 59-73 have been considered but are moot in view of the new ground(s) of rejection.



***Conclusion***

6. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

7. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Mike Qi whose telephone number is (571) 272-2299.

The examiner can normally be reached on M-T 7:30 am-6:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Mike Qi/  
Primary Examiner, Art Unit 2871